

L Number	Hits	Search Text	DB	Time stamp
1	3	6709652.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 13:43
2	3	6709562.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 14:06
3	2	cretz	USOCR	2004/09/22 14:06
4	2	cretz	USPAT; US-PGPUB	2004/09/22 14:07
5	85	(205/123 205/296) and semiconductor and brightener	USPAT; US-PGPUB	2004/09/22 14:29
6	0	brightener same (bismuthiol "2,5-dimercapto-1,3,4-thi?diazole" "1,3,4-Th?diazole-2,5-dithiol")	USPAT; US-PGPUB	2004/09/22 14:31
7	3	brightener same (bismuthiol (dimercapto near4 thi?diazole) (Th?diazole near3 dithiol))	USPAT; US-PGPUB	2004/09/22 14:31
8	3	brightener same (bismuthiol (dimercapto adj4 thi?diazole) (Th?diazole adj3 dithiol))	USPAT; US-PGPUB	2004/09/22 14:39
9	1423	brightener same concentration	USPAT; US-PGPUB	2004/09/22 14:39
10	51	brightener with concentration and semiconductor with copper	USPAT; US-PGPUB	2004/09/22 14:40
11	55	brightener with concentration and semiconductor with copper	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 14:49
12	19	"bis-sodium-sulfonopropyl-disulfide"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 14:48
14	19	brightener with ppm and semiconductor with copper	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 14:57
13	269	brightener with ppm	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 15:01
15	116	(brightener with ppm) and copper	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 15:14
16	16	(4,490,220 4,347,108 4,278,739 4,272,335 3,798,138 3,770,598 3,725,220).pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 15:23
17	3	3778357.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 15:43
18	29	brightener with bis with (sulfopropyl sulfonopropyl) with disulfide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 15:55

19	0	suppresor with polyether	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:35
20	0	suppresor same polyether	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:35
21	52	suppressor with polyether	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:36
22	30	(suppressor with polyether) and semiconductor with copper	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:36
23	457	polyether and semiconductor with copper	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:36
24	123546	polyether samesemiconductor with copper	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:36
25	14	polyether same semiconductor with copper	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:39
26	10	(5,068,013 5,174,886 5,051,154 3,876,513 5,068,013).pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:44
27	126	disulfide with (\$3sulfopropyl \$3sulfonopropyl)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:45
28	34	disulfide with (\$3sulfopropyl \$3sulfonopropyl) with bright\$5	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:45
43	2	5972192.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/22 17:52